# Secure optical communication system utilizing deformable MEMS mirrors

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#### **ABSTRACT**

An optical communication system suitable for voice, data retrieval from remote sensors and identification is described. The system design allows operation at ranges of several hundred meters. The heart of the system is a modulated MEMS mirror that is electrostatically actuated and changes between a flat reflective state and a corrugated diffractive state. A process for mass producing these mirrors at low cost was developed and is described. The mirror was incorporated as a facet in a hollow retro-reflector, allowing temporal modulation of an interrogating beam and the return of the modulated beam to the interrogator. This system thus consists of a low power, small and light communication node with large (about 60°) angular extent. The system's range and pointing are determined by the interrogator /detector / demodulator (Transceiver) unit. The transceiver is comprised of an optical channel to establish line of sight communication, an interrogating laser at 1550nm, an avalanche photo diode to detect the return signal and electronics to drive the laser and demodulate the detected signal and convert it to an audio signal. A functional prototype system was built using a modified compact optical sight as the transceiver. Voice communication in free space was demonstrated. The design and test of major components and the complete system are discussed.

Keywords: Optical communication, line of sight communication, MEMS deformable mirror, retro-reflector

#### 1. INTRODUCTION

Retro-reflectors have been used in optical systems for some time in applications requiring a precise return of a parallel beam of light to its source. A common application uses a retro-reflector as a passive component to return incident laser pulses to the location of a pulsed laser source, allowing round trip time of flight measurement and thus precise range measurement. Active retro-reflectors are a more recent invention, and are generally retro-reflectors that can *modulate* an incident laser beam before returning it to the source. These so-called modulated retro-reflectors (MRRs) offer an intriguing option for laser communication, since they automatically return remote information (without the need for beam steering) to an interrogating source, and do not require transmission source at the MRR. This allows low-power, covert communication. The concept was first patented in an embodiment comprised of a retro-reflector and a liquid crystal shutter [1]. Subsequently, researchers at the Naval Research Laboratory have made considerable progress in developing MRRs using multiple quantum well (MQW) shutters [2-5]. These devices offer bandwidths of tens or hundreds of MHz, and can be quite compact. The MQW approach works over a narrow range of interrogation laser wavelengths, and is relatively expensive to manufacture. Therefore, it is not suitable for low-cost, flexible, remotesensing applications. A number of groups have developed very short range MRRs using microelectromechanical systems (MEMS) using both MEMS corner cubes [6-8] and micro-scale cat's eye retro-reflectors [9-10]. These promise low cost, but are range limited to several tens of meters.

The present work is intended to fill a gap in these approaches: MEMS-based MRRs suitable for low-cost, compact communication over hundreds of meters. A compact, low-power device has been developed to detect and modulate an incoming laser beam, and then return the modulated signal back to the location of the sender. MRR at the heart of this device consists of a MEMS based electromechanical modulator combined with a passive retro-reflector (e.g. a hollow retro-reflector). The modulator serves as one (or more) of the three reflective facets of the retro-reflector. The MEMS

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modulator can be made to act as a plane mirror, maximizing the amount of light that is retro-reflected, or it can be made to act as a non-plane (corrugated) mirror, reducing the amount of light that is retro reflected. One of these states requires no power to maintain, and the other uses only microwatts. The modulation frequency can go up to at least a megahertz with conventionally processed MEMS fabrication tools and materials. Data to be sent from the MRR could include voice communication, remotely sensed environmental information, or identification information. A key attribute of this system is that the transmission power and pointing control required for long-distance communication are delivered by the *interrogating* beam. That is, the strength of the interrogating beam determines the strength of the returned beam (and thus the range). Furthermore, the noise-limitations for the system are contained in the receiver co-located with the sending beam. Almost no power is required at the MRR.

In this paper, design, fabrication, and testing of the MEMS modulator is detailed, and integration of the modulator with a hollow retro-reflector is described. A prototype laser communication system built with the MRR is introduced. In that prototype system, analog audio data from a microphone is frequency modulated and used to drive the MEMS optical modulator that is embedded in a wearable hollow retro-reflector. The MRR unit is interrogated by a compact laser transceiver system that is comprised of a 1.55µm wavelength 10mW laser and driver, a magnified optical visible channel and receiver, an avalanche photodiode, a frequency to voltage demodulator, and an amplifier and speaker. With this system, secure, one-way audio communication over several hundred-meter range has been demonstrated.

#### 1.1 Principle of operation

The MEMS modulator alternates between two states: A flat state, returning most of the incident power to the source, and a corrugated state, that acts as a diffraction grating, diverting a significant amount of the light to higher orders, thus depleting the zero order return. The blinking MEMS mirror modulates an interrogating CW laser beam, returning optically encoded information to the source location, where it is decoded.

# 2. SYSTEM DESCRIPTION

The work described in this paper is motivated by the need to fill a gap in available MRR technology by developing and demonstrating an inexpensive MRR communication system with extended range operating at relatively low power. There is a need for systems with bandwidth greater than 100kHz, size less than 100cm<sup>3</sup>, and range up to 1 km. The basic concept of the system is illustrated in Fig. 1: An electrically modulated deformable MEMS mirror is embedded in a hollow retro-reflector, optically modulates an interrogating laser beam and returns the modulated signal to the interrogating source, where it is decoded.

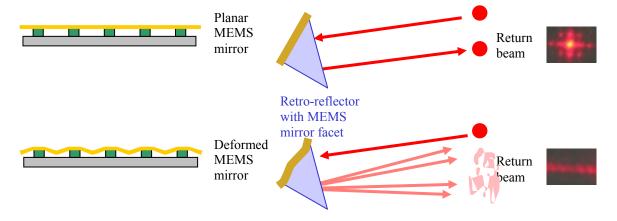


Fig. 1: Principle of operation

The system is comprised of two main parts: The Retro-Communicator and Transceiver. The Retro-Communicator uses analog audio data from a microphone to frequency modulate the drive signal to the deformable MEMS mirror. The modulator is embedded in a hollow retro-reflector and thus sends the modulated signal back to the interrogator (Transceiver), where it is received, demodulated and converted back to an audio signal.

## 2.1 Retro-Communicator

The Retro-Communicator is conceptually comprised of two parts: The *Optics Module* and the *Electronics Module*. These two parts are combined in one small box, shown in Fig. 2.



Fig. 2: Retro-Communicator Module

The Optics Module contains the deformable mirror (DM) embedded in a hollow retro-reflector as seen in Fig. 3

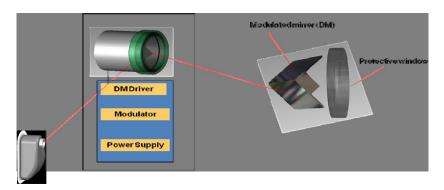


Fig. 3: The Retro Communicator block diagram (Optics and Electronics)

The Electronics Module contains the modulating electronics to drive the DM, as well as batteries, high voltage DC power generation, and a microphone input.

#### 2.2 Transceiver

The Interrogator/Transceiver is comprised of  $1.55 \, \mu m$ , 10 mW, CW laser, a magnified visual aiming channel and receiver, an avalanche photodiode detector, a frequency to voltage demodulator, and an amplifier and speaker. The Transceiver is shown in Fig. 4 and a block diagram is shown in Fig. 5.



Fig. 4: Transceiver

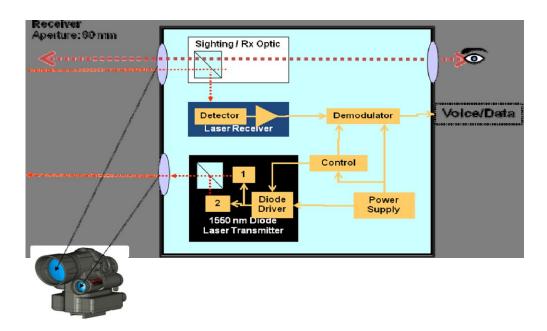


Fig. 5: Transceiver block diagram

#### 3. DEFORMABLE MIRROS

In this section, we describe the main component of the system and their characteristics.

#### 3.1 Modulator design and fabrication

To modulate the intensity of the interrogating laser beam, a reflective MEMS mirror was designed that is optically flat in its "off" state and a diffraction grating in its "on" state, thereby deflecting most of the incident beam energy out of the reflection path. The architecture for the modulator, illustrated in Fig. 6, uses electrostatic actuation to deform rows of edge-supported narrow plates to form a diffraction grating. By maintaining the reflective gold mirror surface, supported by a tensile silicon nitride layer, at a ground potential and applying a voltage to the conductive substrate, an electrostatic force is generated between those two surfaces resulting in deflection of the flexible mirror surface.

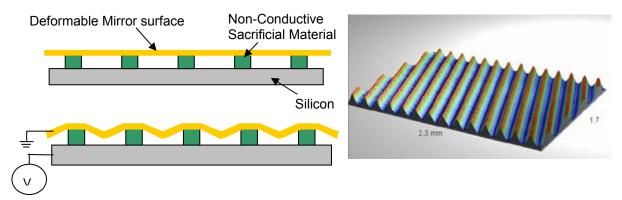


Fig. 6: Illustration of MEMS Modulator architecture

This actuator may be modeled as a pair of closely-spaced planar electrodes having overlapping area A and spacing g across which a voltage V is applied. The electrostatic attractive force  $F_e$  between the electrodes is given by:

$$F_e = \frac{\varepsilon_o A V^2}{2g^2}$$

where  $\varepsilon_0$  is the permittivity of air  $(8.8 \times 10^{-12} \text{ F/m})$ . If the electrodes deflect toward one another by an amount z, the attractive force is modified:

$$F_e = \frac{\varepsilon_o A V^2}{2(g-z)^2}$$

If one actuator electrode remains fixed, and if the other movable electrode is supported by a mechanically compliant spring having stiffness k, the mechanical restoring force  $F_m$  opposing electrode motion can be expressed by:

$$F_m = -kz$$

At equilibrium, the electrical and mechanical forces balance ( $F_e = -F_m$ ). One can easily derive an equation relating the equilibrium deflection z and the applied voltage V:

$$V = \sqrt{\frac{2kz(g-z)^2}{\varepsilon_o A}} \tag{1}$$

This nonlinear relationship is an approximation because the real actuator membrane bends and does not deflect as a rigid, flat electrode. Moreover, the mechanical restoring force is affected by residual stress in the actuator membrane and does not exactly follow a linear force-displacement law. Nevertheless, Equation 1 illustrates the general relationship between g, z, and V.

Using electrostatic actuation to modulate the interrogating beam has the benefits that the actuators consume almost no power, exhibit no hysteresis, and the deformable mirrors are relatively easy to fabricate in standard semiconductor fabrication processes. An illustration of the fabrication process flow is shown in Fig. 7.

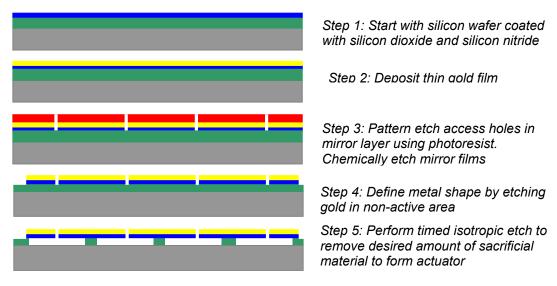


Fig. 7. Schematic cross section of modulator fabrication process

The process uses an optically-flat, electrically-conductive silicon substrate onto which thin films of silicon dioxide and silicon nitride are deposited (step 1). A 90-nm thick gold film is then deposited using an e-beam evaporator (step 2). The gold film is lithographically patterned and etched to form small, 4-µm holes. The patterned gold film is then used as a

mask to etch the small holes into the silicon nitride using reactive ion etching (step 3) that are used to define the shape of the actuators during release. The layout of the reflective gold modulator, shown in Fig. 8, is defined by a second photoresist pattern which removes the gold from non-active regions (step 4). Lastly, the silicon dioxide layer is partly etched using hydrofluoric acid, leaving behind small actuator anchors (step 5) and forming the electrostatic actuators. The finished modulator has an active diameter of 9 mm.

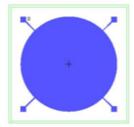


Fig. 8: The area in blue is the shape of gold film and defines the active aperture of the device.

## Modulator optical and electromechanical characterization

Optical and electromechanical characterization of the MEMS modulators was performed using both a Wyko surface mapping interference microscope as well as an optical setup that simulated retro-reflector performance in the field. In operation, light returned from a modulator with a 9mm diameter separated at a distance on the order of a few hundred meters from the interrogating source can be described using Fraunhofer diffraction theory. When the modulator is in the "on" state, the retro-reflected beam returned to the interrogator receiver aperture corresponds to the 0<sup>th</sup> order of the diffracted wavefront. To simulate device performance in the lab, the far-field diffraction pattern is simulated using a lens located a focal length from the modulator. By placing a high speed photo detector at the Fourier plane of the lens (back focal plane), intensity changes in the 0<sup>th</sup> diffraction order can be monitored as the modulator transitions between the on and off states, providing both static and dynamic evaluation of modulator behavior.

The optical setup for the modulator characterization system can be seen in Fig. 9. The primary components consist of: A 635nm wavelength laser diode (LD) for illumination, lenses (L1 and L2) to expand the illumination beam to fill the full modulating retro-reflector mirror (MRM) aperture (at normal incidence), and lenses (L3 and L4) to project a representative far-field diffraction pattern onto a fast 2.1MHz bandwidth photo detector (PD). The photo detector uses an adjustable iris to block everything but the 0<sup>th</sup> diffraction order. For ease of use with existing voltage driver hardware, the tested modulators were packaged in a ceramic 144-pin grid array (PGA) package, which can be seen in Fig. 10. Voltage is supplied to the modulator gold layer via four wire bond-PGA connects, and the silicon substrate is grounded to the PGA floor using silver epoxy.

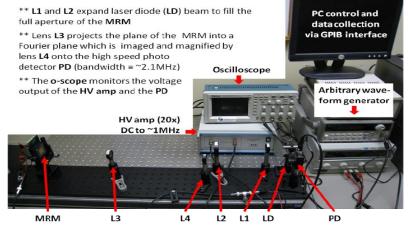


Fig. 9: Modulator optical characterization system

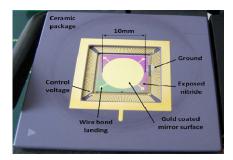


Fig. 10: Modulator packaged in ceramic PGA for testing purposes.

The mirror flatness was measured using the Wyko surface interference microscope. The results are shown in Fig. 11. Typical mirror surface flatness for the full mirror aperture is about 10nm RMS. The local surface quality is also on the order of 10nm RMS, primarily a result of the etch-access holes and actuator anchor pattern.

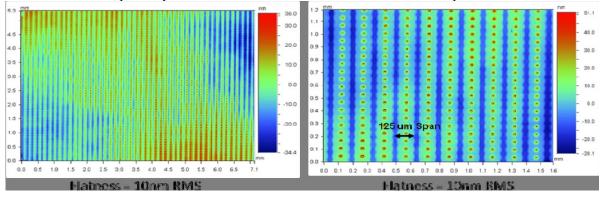


Fig 11: Surface figure measurements of the unpowered modulator: full aperture (left) and high magnification (right).

The  $0^{th}$  order of the "far-field" diffraction pattern is projected onto the photo detector pupil, as shown in Fig 12, such that only this order's intensity can be recorded for different modulator deflections. As previously mentioned, the detected  $0^{th}$  order intensity is analogous to what an interrogating illumination system would receive from the modulator in the field if it were mounted in a retro-reflector assembly. As the modulator deflects, the intensity of the  $0^{th}$  diffraction order decreases while off-axis higher diffraction orders increase in intensity. The output voltage of the photo detector (PDV) is recorded using an oscilloscope. Typical opto-electromechanical behavior for two modulators with a grating pitch of a  $150\mu m$ , and spans of  $90\mu m$  and  $125\mu m$ , can be seen in Fig 13. This data was obtained using both the optical characterization system discussed above, as well as the Wyko surface mapping interference microscope. The combination of these datasets provides an empirical relationship between  $0^{th}$  order diffraction intensity and modulator deflection. Apparent in these characterization results is that a reduction in modulator span requires an increase in voltage to achieve identical modulator deflections. This is due to an increase in modulator membrane stiffness with a decrease in span. Stiffness is inversely proportional to span [11].

When mounted in the hollow corner cube retro-reflector configuration, light is incident on the modulator surface at a 45 degree angle, and the plane of incidence, which is orthogonal to the plane of the grating, is rotated by 45 degrees with respect to the grating profile. This influences the phase matching conditions that create the individual diffraction orders, which reduces the modulation contrast achievable for a given modulator deflection value. In other words, the relationship between modulator deflection and 0<sup>th</sup> order diffraction intensity experiences a shift towards higher deflection, as shown in Fig 14 for the 90µm span modulator design. In order to achieve the same modulation contrast, the modulator must deflect further. Also shown in Fig 14 is that modulation contrast is uninfluenced by rotation of the grating profile with respect to the plane of incidence. At a 45 degree angle of incidence, modulation contrast remains the same when the grating orientation is rotated by 90 degrees relative to the plane of incidence.

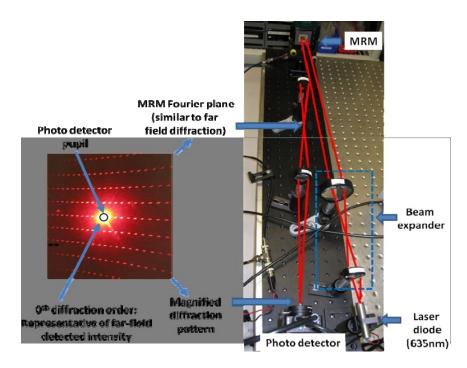


Fig. 12: "Far-field" modulator diffraction pattern (left) and optical characterization system (right). Photo detector pupil located at 0<sup>th</sup> diffraction order.

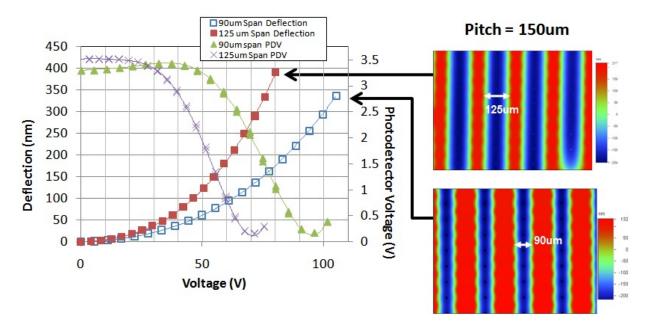


Fig. 13: DC characterization of modulators with 125μm and 90μm spans (both with grating pitch of 150μm) (Left). With increased stiffness, the applied voltage-deflection relationship for the shorter span device shifts to the right. Deflected modulator surface measurements shown at 80V and 105V for the 125μm and 90μm designs respectively.

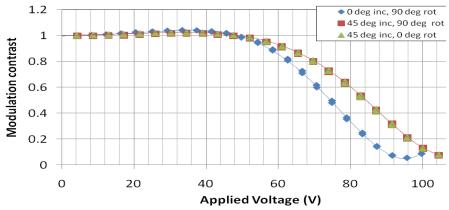


Fig. 14: Modulation contrast for the 90um span device at 0 degree and 45 degree incidence. A 90 degree rotation of the modulator around its surface normal does not change modulation contrast performance. The results are scaled by the 0V contrast value.

In addition to the DC characterization of the  $90\mu m$  and  $125\mu m$  span modulators, the optical characterization setup was also used to perform an intensity-based measurement of modulator dynamics at standard pressure. A sinusoidal voltage was applied to these devices with variable frequency and amplitude. The modulation contrast of the detected signal at normal incidence was measured using the photo detector, and calculated as  $(V_{max} - V_{min}) / (V_{max} + V_{min})$ . These results can be seen in Fig. 15, where an increase in the primary resonance of about 100kHz is apparent for the stiffer  $90\mu m$  span device. Modulation contrast was examined at additional voltages, although only a few are displayed in this figure.

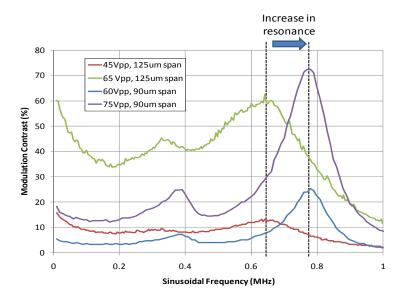


Figure 15: Modulation contrast response to sinusoidal drive voltage at variable frequencies and amplitudes.

To evaluate the influence of air damping on the dynamic performance of the modulator, the step response of the modulator to a 0 to 60V square wave (at 40kHz) was also evaluated using the optical characterization setup. The results of these measurements for the  $125\mu m$  span modulator at 760 Torr and 250 Torr can be seen in Fig. 16. Here it is apparent that the prototype device behaves as an under-damped harmonic oscillator with atmospheric resonance of approximately 690kHz, and a settling time of approximately  $10\mu s$ . Faster settling time could be achieved by increasing device damping through pressurized packaging, as well as changing the mechanical resonance of the MRM. Also apparent in the ringing behavior of Fig. 16 (right) is overshoot of the modulator membrane as it returns to the off-state, seen as the double peaks in the recorded data.

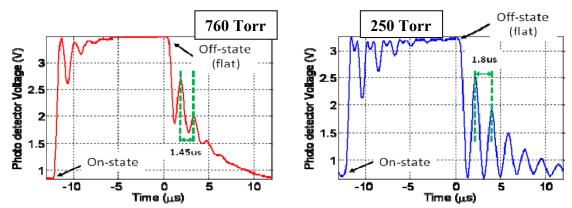


Fig. 16: Dynamic response of the 125μm span modulator to a 0 to 60V, 40kHz square wave, as seen by the photo detector in the optical characterization system; 760 Torr (left) and 250 Torr (right). Atmospheric resonance was approximately 690kHz, with a 10μs settling time. The peak detector intensity corresponds to the modulator in its off (flat) state.

As previously described, the characterization of the modulator was performed using visible 635nm light, where in the retro-reflector application IR radiation with a wavelength of 1550nm is used. To understand the change in modulator performance, an optical model was developed by applying scalar diffraction theory or Fourier optics to determine the influence of modulator shape on diffraction efficiency. In this simulation, it was assumed that the modulator imparts a sinusoidal varying phase on the reflected beam. These results can be seen in Fig. 17 for both 630nm and 1550nm, where the normalized peak intensity of the diffracted 0<sup>th</sup> order is plotted for variable modulator deflection depths. In this comparison of modulation contrast for a sinusoidal grating, similar to the modulator presented here, it can be seen that about 240nm of deflection is necessary to achieve maximum contrast in the visible, where about 600nm of deflection is necessary at 1550nm. The visible results for this model agree closely with the experimental behavior presented above in Fig. 13. Therefore to achieve optimum modulation contrast in the infrared, a larger device gap will be necessary in future devices. The present device is only capable of deflections on the order of 400nm before experiencing the unstable electrostatic "pull-in" behavior.

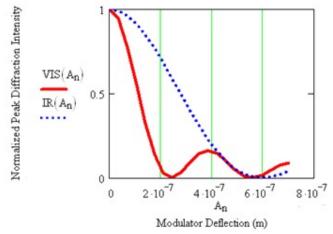


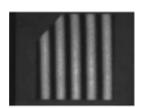
Fig. 17: Comparison of theoretical modulation contrast for on-axis diffraction intensity in both visible and infrared for a 150um pitch grating with sinusoidal cross-section. Optimum performance is achieved at a deflection of 240nm in the visible (630nm) and 600nm in the IR (1550nm).

#### 4. RETRO-REFLECTOR

## 4.1 Hollow retro-reflector

Hollow retro-reflectors are used in many applications where a parallel beam of light needs to be returned with great precision to its source. The most significant property of the hollow retro-reflector is that it works as a self compensating

flat mirror that will preserve its original polarization. Interferogram of a flat mirror and a hollow retro-reflector are presented in fig. 18.



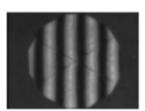




Fig. 18. Interferogram of a flat mirror and a retro-reflector. Left image is one of the flat mirrors used to construct the retro-reflector (middle image). Glass hollow retro-reflector (right image)

Hollow retro-reflector is fabricated by utilizing three flat mirrors, usually in a square shape. The mirrors are bonded or fused together along one edge to create a corner cube with three mirror surfaces attached to each other at substantially 90 degrees as shown in Fig. 18.

A more common form of a retro-reflector is a corner cube prism, also referred to as a solid retro-reflector. Unlike the solid retro-reflectors where the light beams have to pass through a medium, (glass or other substrate) in a hollow retro-reflector configuration the reflection is a pure single surface reflection. The single surface reflection enables reflection of all wavelengths, this advantage makes the hollow retro-reflectors extremely advantageous in applications were high reflectance of infrared beams is desirable and the use of exotic materials makes the project prohibitively expensive. The standard hollow retro-reflectors are made from Boron Silicate glass or Pyrex.

#### 4.2 Hollow retro-reflector made from silicon substrate.

Silicon wafer based mirror is highly resistant to deflective distortions, having a specific stiffness (E/p - Young's Modulus divided by density) on the order of 1.5-2.5 times better than BK-7, Zerodur, Aluminum and other similar precision mirror substrate materials. The high stiffness of the silicon enables an aspect ratio of approximately 150 to achieve a six (6) waves @633nm flat polished surface, with 80 angstroms surface quality, over a 6" round wafer. The silicon mirrors used in our retro-reflector are squares having the dimensions of 10mm x 10mm x 0.7mm. The mirrors were cut from a silicon wafer and are gold coated. Initial flatness was measured without any stress and shows 0.4 waves P.V @ 633nm. The mirror was diced from a 6" polished silicon wafer. It is evident from the flatness measured that distortion resulting from the dicing operation was kept to minimum. There are no signs of any stress resulting from the cutting since the fringe line is almost straight to the edge. See Fig. 19 for an interferogram of the diced mirror.

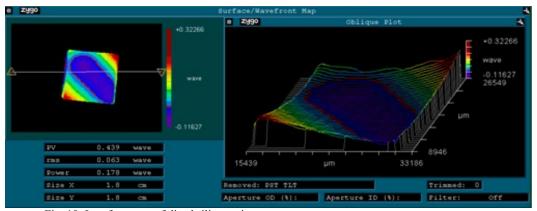


Fig. 19: Interferogram of diced silicon mirror

Assembly of hollow retro-reflector from 3 silicon wafer mirrors presents a unique challenge. The mirrors are extremely thin, 0.7mm, they are gold coated, and the edges are not perfectly flat since they were not ground and polished. Fig 20 shows the assembled unit as well as its resulting interferogram. Special tools needed to be designed to hold the mirror without leaving fingerprints on the gold surface.

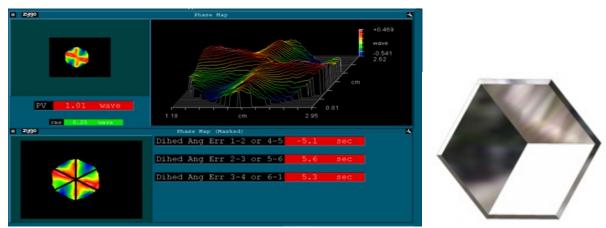


Fig. 20: Wavefront of the assembled silicon wafer retro-reflector shown on right

Subsequent to the initial assembly of plain mirrors into a retro-reflector assembly, additional prototype retro-reflectors comprising of one (Deformable Mirror) DM modulator and two (2) silicon wafer mirrors were assembled. Assembly and handling the DM is especially difficult because any contact with the DM surface can deem it un-usable. Special tools were designed and built to avoid all front surface contact and handling and positioning stress. The resulting wavefront is shown in Fig. 21.

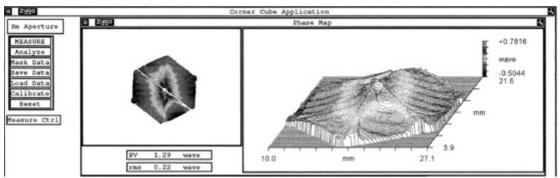


Fig. 21: Wavefront of assembled silicon wafer/Deformable Mirror retro-reflector

# 4.3 Modulator performance

Measurements of the performance of the modulated retro-reflector were performed. The set-up was similar to the set-up shown in Fig.12. The only difference was incorporation of a beam splitter after the retro-reflector, and building the detection optics beyond the beam splitter. The set-up is shown in Fig. 22.

The results are, as expected, very similar to the results measured with the raw modulator, as can be seen in Fig. 23.

The modulation contrast of the mirror when incorporated in the retro-reflector at a certain applied voltage is lower than the modulation contrast measured at the same voltage with the mirror when not in the retro-reflector. This can be explained when looking at Fig. 14. As can be seen in Fig. 14, the modulation contrast at 45° at the same voltage is lower than at normal incidence. Since the mirror is viewed at 45° when part of the retro-reflector, these results are consistent. The same high modulation contrast seen in the original measurements can be achieved at a higher applied voltage.

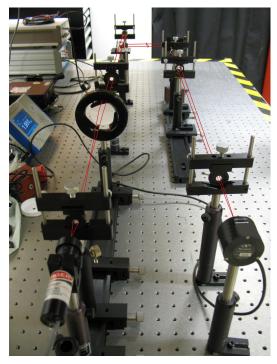


Fig. 22: Modulated retro-reflector (MRR) characterization set-up

#### ک KHz

Modulation depth of retro-reflector

Fig. 23: Modulation contrast response to square wave drive voltage at variable frequencies and amplitudes

# 5. SYSTEM CHARACTERIZATION

#### 5.1 System performance

The system was tested at Devens at ranges to over 200m and performed well. The audio was clear at any range between 25 and 220m. We also performed signal to noise measurements on the system, simulating range by optical attenuation. The measurements were done with input at 1V rms, 1kHz, using a spectrum analyzer and an arbitrary waveform generator. The electronic design of the system includes an Automatic Gain Control (AGC) at the output of the demodulator. The effect of the AGC is that with a reduction in signal level, the gain increases. When the gain gets high enough for the noise to start increasing visibly, the AGC can still maintain the signal level. At the limit of the gain, the signal level starts to decline. The signal to noise measurement results are shown in Fig. 24. These results agree with the design goal.

The system's audio performance as a function of angle of incidence of the interrogating beam was also evaluated. The audio did not start deteriorating until about 30° off axis in each direction. Signal to noise measurements as a function of angle of incidence were performed, using the same equipment as described above. The results are shown in Fig. 25. The signal to noise measurements agree well with our qualitative audio evaluation. We saw the signal to noise deteriorate rapidly at the edge of the range/angular range. Measurements show that the audio quality deteriorates when the signal to noise ratio goes below about 25.

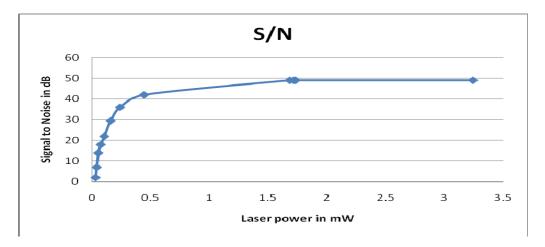


Fig. 24: Measurement of signal to noise ratio of the communication system as a function of the interrogating laser power.

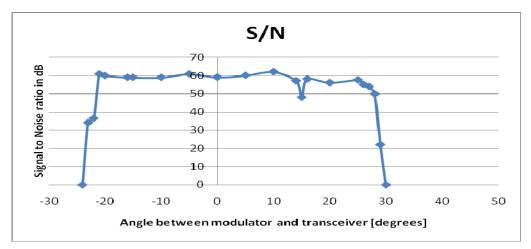


Fig. 25: Measurement of signal to noise ratio of the communication system as a function of angle between the transceiver and the modulator.

#### 6. CONCLUSIONS

An optical communication system using a modulated MEMS mirror embedded in a hollow retro-reflector was constructed and evaluated. The system, using a low laser power of 10mW, demonstrated audio communication to over 200m. This system is small, low cost, low power, and could easily be extended to ranges of about 1 km. The system fills the need of a low cost, small modulated retro-reflection system with extended range. The system is particularly useful for applications when the interrogator is remote (e.g. on an aerial vehicle) and the communication needs to be covert (e.g. getting data from concealed unattended ground sensors, identification etc.).

The described measurements and analysis demonstrate that some design parameters will need to change for the next generation modulator. As seen, the mirror will need a larger range of deflection to maximize the performance at  $1.55\mu m$ . Nevertheless, the system performed well with a non-ideal contrast.

Improving the deflection range of the mirror, as well as increasing the laser power, can increase the system's range to about 1 km.

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